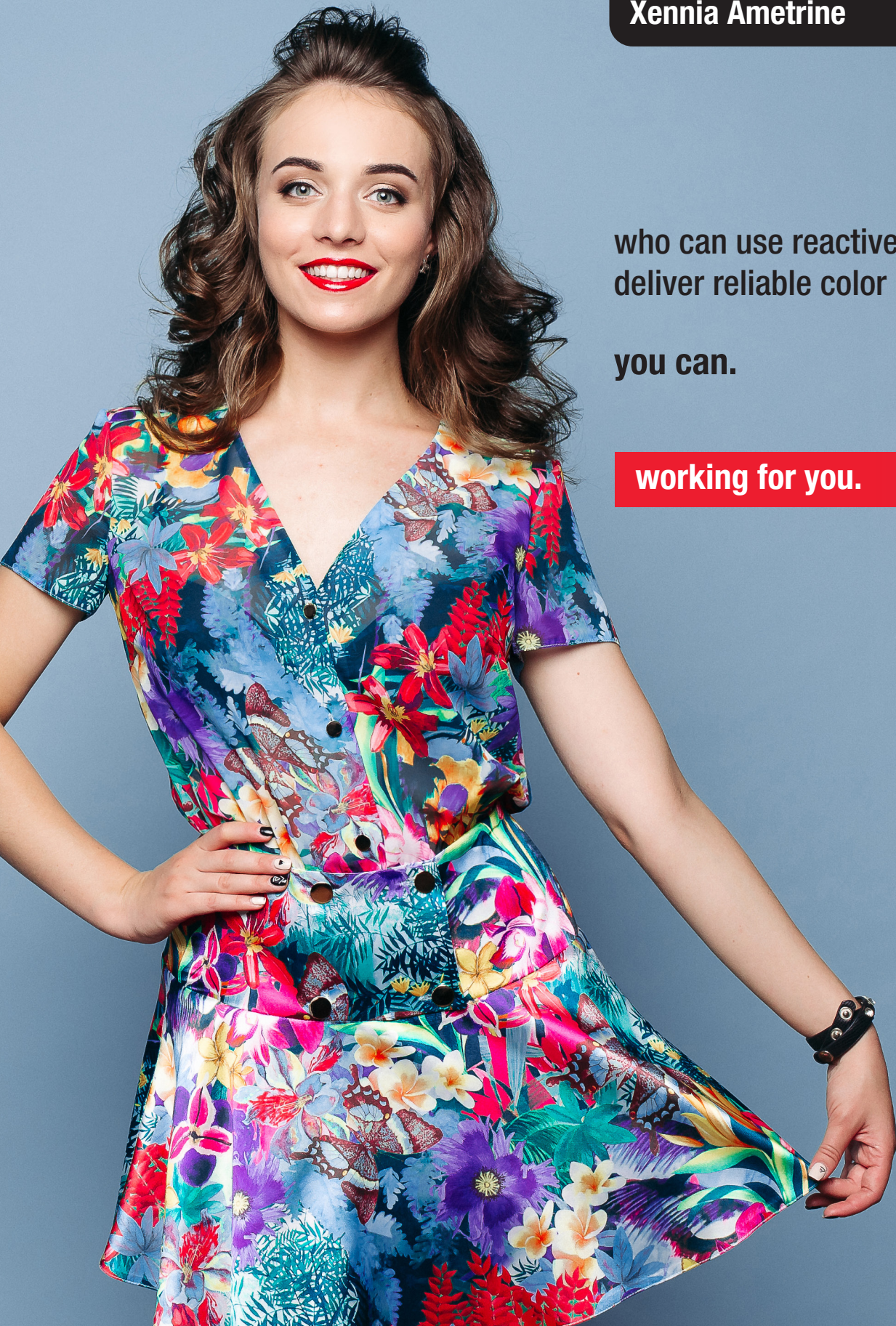


Xennia Ametrine

who can use reactive technology to
deliver reliable color performance?

you can.

working for you.



SunChemical®
a member of the DIC group 
Color & Comfort

Advanced technology delivering detailed, consistent color

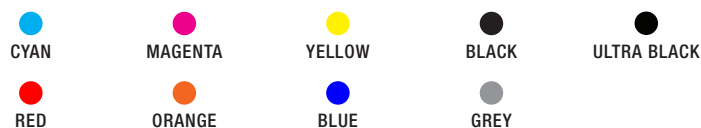
Sun Chemical brings life to designs with Xennia Ametrine, a reactive solution for industrial printers looking for bold colors and sharp detail without compromising reliability. Extensively tested in high productivity, three shift production environments, Xennia Ametrine gives volume printers peace of mind with maximized uptime and consistent, reliable color.

Xennia Ametrine is a high-quality, consistent ink that is specially formulated to enable faster and more efficient production. This ensures volume customers meet their most demanding targets in fashion and home textiles.

Key performance benefits

- Key performance benefits:
- Simple installation
- Consistent color performance
- Repeatable industrial production
- Excellent printhead compatibility
- Batch to batch uniformity

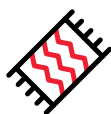
Available colors



Applications for XENNIA Ametrine



Fashion apparel



Home Textiles

Differentiation through innovation

Working with customers to understand the pressures of high volume printing, we have developed a formulation and production process to deliver a solution that is simple to use, allows maximum printer uptime and maintains the color performance you expect from Sun Chemical products.

See it to believe it



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